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The functionalization of nanodiamonds (diamondoids) as key parameter of their easily controlled self-assembly in micro- and nanocrystals from vapor phase

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We detail herein readily accessible processes to control previously unobserved robust self-assemblies of nanodiamonds (diamondoids) in micro- and nanocrystals from their mild vapor deposition. The chemical functionalization of uniform and discernible nanodiamonds was found a key parameter, and depending on the type of functional group (hydroxy, fluorine, etc.) and its position on the diamondoid, the structure of the discrete deposits can vary dramatically. Thus, well-defined anisotropic structures such as rods, needles, triangles or truncated octahedra shapes can be obtained, and self-assembled edifices of sizes ranging from 20 nm to several hundred micrometers formed with conservation of a similar structure for a given diamondoid. Key thermodynamic data including sublimation enthalpy of diamondoid derivatives are reported, and SEM of the self-assemblies coupled with EDX analyses and XRD attest for the nature and purity of nanodiamonds crystals deposits. This attractive method is simple and outperforms in terms of deposit quality dip-coating methods we used. This vapor phase deposition approach is expected to allow for an easy formation of diamondoid nanoobjects on different types of substrates.

Introduction

Diamondoids are cage hydrocarbon molecules that can be described as fully hydrogen-terminated nanometer-sized diamonds. Adamantane (1) and diamantane (2) are the smallest diamondoids and their selective functionalization can be achieved with high efficiency at various positions of the hydrocarbon cage (Fig. 1). Ultra-disperse detonation nanodiamond, and diamondoids (also called nanodiamonds) have shown impressive success in the utilization of diamond properties in various areas that span the fields of nanomedicine, nanodevices for energy, and molecular machines. For instance, large area self-assembled monolayers of thiolated diamondoids on gold surfaces exhibit intense monochromatic photoemission with energy distribution width < 0.5 eV, which is related to the negative electron affinity of the surface-attached nanodiamonds.

Another attractive and hitherto unmet challenge in this field is the construction of organic materials and organohybrids based on nano- and microcrystals of functionalized diamondoids. Based on such edifices, carbon nucleation followed by growth may also pave the way to access continuous diamond thin films of better defined structure and surface. Diamondoids may serve also as precursors in “bottom-up” strategies to build organohybrids, and to devise diamond structures under conditions that are possibly milder than the chemical vapor deposition (CVD) conditions currently used for diamond growth. Methods have been reported akin to CVD that yielded higher diamondoids (more than four carbon fused-cages) and even diamond from diamondoid seeds.
However, for applications of nanodiamonds-based materials built “bottom-up” there is still a need for better fundamental understanding and mastering of the conditions of nucleation, growth and self-assembly of diamondoids units. Additionally, general interest in dispersed micro- and nanocrystals stems from the fact that their properties dramatically change with their size and shape, and many applications from optical (plasmon absorption) to medical (transportation through biological barriers) illustrate this point. We thus report on readily accessible processes for the mild vapor deposition of functionalized diamondoids that provide robust self-assembly of nanodiamonds micro- and nanocrystals. Key thermodynamic data including sublimation enthalpy of several diamondoids derivatives are reported from a new measurement protocol at solid-vapor thermodynamic equilibrium state. Easily accessible processes for self-assembled edifices of sizes ranging from 20 nm to several hundred micrometers are reported with remarkable conservation of the general geometry for a given diamondoid, chemical analysis with microscopy ascertaining the full preservation of the nature of nanodiamonds.

Results and Discussions

Due to the volatility of adamantane (1) and diamantane (2) (Fig. 1), we envisioned that vapor deposition of functionalized diamondoids might be a general and convenient access to nanocrystals, microcrystals, and thin films of carbon-based materials. The control of a given vapor deposition process entails knowledge of the partial pressure of the source under the experimental conditions. Accordingly, enthalpies of sublimation are critical thermodynamic properties of the condensed phase in relation with vapor pressure. Therefore, our vapor deposition studies were first devoted to measuring sublimation enthalpies of pristine adamantane and diamantane for which different values have been reported. Conversely, fundamental studies of the vapor pressure of functionalized diamondoids remain very limited. We found significant differences in the reported values for the enthalpies of sublimation (see SI, Table 1S), depending on the measurement and calculation methods. Mainly destructive calorimetric measurements had been conducted using total combustion of the diamondoids in a bomb calorimeter. This prompted us to develop an alternative experimental method to measure the vapor pressure of functionalized diamondoids at the solid-vapor thermodynamic equilibrium state. In this process the diamondoids were brought into the sublimation regime in a chamber connected with a Pirani vacuum gauge at ±0.13 Pa (i.e. ±1 µm Hg) and the pressure was continuously monitored until the equilibrium state was reached. The temperature dependence of the vapor pressure for the diamondoids 1–5 follows the Clausius-Clapeyron equations given in Table 1.

<table>
<thead>
<tr>
<th>Table 1. Thermodynamic data for sublimation of 1–5a</th>
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<tr>
<td>Clausius-Clapeyron equations</td>
</tr>
<tr>
<td>ln P = -7212.4/T + 26.869</td>
</tr>
<tr>
<td>ln P = -11073/T + 37.172</td>
</tr>
<tr>
<td>ln P = -12282/T + 39.589</td>
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<tr>
<td>ln P = -13087/T + 42.196</td>
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<tr>
<td>ln P = -11597/T + 38.335</td>
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a pressure in Pa, T in K (see SI for measurement full details).

The enthalpies of sublimation obtained from these equations are ΔH' = 60.0 kJ mol⁻¹ for 1, 92.1 kJ mol⁻¹ for 2, 102.1 kJ mol⁻¹ for 3, 108.8 kJ mol⁻¹ for 4, and 96.4 kJ mol⁻¹ for 5, indicating the highest volatility for adamantane, and the lowest for hydroxydiamantane derivatives. The enthalpy of sublimation obtained for adamantane 1 following equilibrium state pressure measurements, ΔH₀ = 60.0 kJ mol⁻¹ (14.3 kcal mol⁻¹), is consistent with the values previously reported (14.2±0.3 kcal mol⁻¹). This was also the case for diamantane 2 measurements (ΔH₀ = 92.1 kJ mol⁻¹), with the values obtained using calorimetry bomb combustion, and gas-saturation temperature scanning (95.9 kJ mol⁻¹). As expected, the fluoro diamantane 5 was found fairly volatile with a ΔH₀ = 96.4 kJ mol⁻¹ approaching the one we found for pristine diamantane. Due to a noticeable hygroscopic behaviour of the hydroxydiamantanes a good reproducibility required cautiously dried finely divided pure hydroxydiamantane powders to exclude water traces. It was determined that 4-hydroxydiamantane 4 is significantly less volatile, ΔH₀ = 108.8 kJ mol⁻¹, than 1-hydroxydiamantane 3, ΔH₀ = 102.1 kJ mol⁻¹.

The vapor deposition of 1–5 was then conducted, under tuneable conditions of pressure and temperature, on silicon and mica substrates using a simple sublimation apparatus (see SI). The deposition experiments were conducted first under air or argon atmosphere 1.0 bar (10¹³ Pa), and then either under static vacuum (initial pressure 5.3 mbar), or dynamic vacuum (5.3 mbar). Temperature conditions ranging between 50 and 110 °C were investigated. Higher sublimation temperatures favour a higher vapor supersaturation regime, which in turn favours effective nucleation in comparison to crystals growth. A good nucleation rate, in comparison to growth rate, then will quickly generate numerous small crystals of critical size that will no longer disappear to serve as “nutrients” for growth of bigger crystals (Ostwald ripening). Deposition times were varied between a few minutes to 16 h. The vapor deposition of a wide variety of functionalized diamondoids was conducted (see SI), including compounds 1–5 (Fig. 2).
Other functionalized adamantane and diamantane derivatives, such as the 1-aminoadamantane, 1-adamantylidiphenylphosphinite, 1-adamantylidiphenylthiophosphinite, 1-ethynyladamantane, 1-hydroxyadamantane, 4,9-dihydroxidiamantane, 4,9-difluoridiamantane were also deposited (see details in SI). Optical microscopy of the deposits was conducted for visual inspection of the obtained deposits. Optimization of the deposition conditions was conducted for the diamondoids that were found most suitable for generating from vapor deposition well-defined crystals self-assembly. As illustrated in Fig. 2, crystals of micrometer size with very different shapes and structures grew depending on the nature of the diamondoid. The deposition of 1 was difficult due to the high volatility of this compound which easily re-evaporates after condensation. The vapor deposition of 2, although easier, resulted in very fragile assemblies that easily broke on handling (see microstructures in SI). Conversely, nice crystalline deposits of well-dispersed homogeneous microcrystals were obtained in less than one hour from the vapor deposition of hydroxyl- and fluoro-functionalized nanodiamonds 3–5. Interestingly, not only the nature of the functionalization shows an overwhelming influence on the self-assembly and thus microstructure of the deposits, but also the position of the functional group on the cage. Thus, from the vapor deposition of 3–5, hexagonal rod, rectangular needle, and triangular plate microcrystals were observed, respectively. The size of the crystals can be adjusted through the duration of the deposition with conservation of excellent dispersion and size homogeneity.

The high crystallinity of the deposits was confirmed by successful single crystal X-ray diffraction analyses conducted on all these samples. For instance, the X-ray diffraction analysis of microcrystals of 3 (Fig. 17S in SI),26 shows the presence of discrete tetramers for which the units are in a cyclic network of O–H…O hydrogen bonding. These tetramers are arranged in 1-D columns. A similar structure was found for 4.

Scanning electron microscopy (SEM) analysis was conducted to examine in further details surface morphologies (Fig. 3). Much to our surprise the SEM images showed that the first deposits elaborated under atmospheric pressure of air or argon does not tolerate the low pressure, 10⁻⁶ mbar, and the voltage imposed by SEM analysis. For instance, deposits of 5 were completely volatilized, and while self-assemblies of 3 and 4 were more resistant, they also showed a tendency toward shrinkage during the analysis. Microcrystals of 3 that appeared as well-defined hexagonal rods in optical microscopy turned into hollow rectangular structures under the SEM conditions (Fig. 3a). The formation of hollow needles was shown for 4 from SEM micrographs (Fig. 3b) with shrinkage also evidenced for the needle crystals from collapsed edges in enhancement pictures (right). Hollow micro- and nanostructures are studied in areas which include catalysis, cosmetics, drug and gene delivery, hydrogen production and storage, photonics, photovoltaics, and rechargeable batteries.27
Mostly metal-based and ceramic hollow micro-/nanostructures have been prepared, commonly from template-removing procedures. To the best of our knowledge, the formation of non-polymeric hollow structures of pure hydrocarbons has not previously been documented. We hypothesized that their formation was due either to some unlikely selective internal volatilization and/or rearrangement of the self-assembly under the SEM conditions, or better to some gas capture—either air or argon—inside the structures during the growth process. To support the latter hypothesis, we tried to protect the diamondoid particles grown under atmospheric pressure by covering them with a 15–20 nm thin layer of gold metal before SEM analysis using sputtering by high resolution ion beam coater. This metallization was also achieved under high vacuum (10⁻⁵ mbar) and consequently the crystal morphologies were modified before the gold layer could fully protect the deposit. However, these experiments established that during the vapor deposition process under atmospheric pressure some gas was trapped inside the self-assembly of diamondoids. As shown in Fig. 3c and 3d respectively, shrinkage of the polyhedral particles based on triangle motifs for 5, and hexagonal rods for 3 were observed, while the gold protective layer roughly conserved the original shape of the edifices.

With the goal of growing crystals in which no gas trapping occurs and that would also be resistant to the SEM conditions, we modified the vapor deposition apparatus used under atmospheric pressure to allow sublimation under 5 mbar reduced pressure (Fig. 16S in SI). We were delighted to confirm the success of this strategy. As illustrated in Figure 3e and 3f, the deposition of microcrystals of about 40 µm was achieved, with the SEM revealing three-dimensional structures fully consistent with the optical microscopy observations. The triangular shapes observed in optical microscopy thus correspond to the faces of regular octahedra resulting of the self-assembly from vapor phase of fluorinated diamondoid 5. The hexagonal rods observed for hydroxylated diamantane 3 revealed an apparent surface roughness that was not observed for 5. EDX microanalysis conducted during the SEM experiments on various areas of the deposited samples confirmed elemental composition and nature of the deposits. This is illustrated in Fig. 4 that presents a deposit of 5 on silicon (area-Spect 3, EDX C_{Kα1}= 0.280 keV, F_{Kα1}= 0.532 keV) and compares it to a pristine zone of the silicon substrate (area-Spect 2, EDX Si_{Kα1}= 1.739 keV). Thus, consistent with the single crystal X-ray diffraction analysis that attested high crystallinity and purity of the deposits, the peaks corresponding to the electron binding energies K_{α1} for C, F and Si were detected depending on the focus area of the beam. The size distribution in Fig. 4 confirmed an average size of 40 µm with the major part of the particles having a size between 25 and 55 µm. More than 90% of the visible aggregates have pyramidal and octahedral shapes, and less than 5% edifices experienced intense Ostwald ripening for reaching sizes above 60 µm.

Heavier plasma-hydrogenated detonation nanodiamond developed by Arnault and co-workers have shown a tendency to self-assembling as aggregates in water solution, depending on counter ions present.²⁸ Our attempts to generate accurate and reproducible self-assemblies such as obtained from vapor phases, but by crystallization from our functionalized diamondoids in solution (dip-coating, dichloromethane, water) were unsuccessful, giving mainly large area covered with isotropic structurally poorly-defined coated material (see optical microscopy and SEM images in SI).

![Size distribution](image)

Fig. 4 SEM micrograph of 5 deposited on a silicon substrate (top). EDX analysis of different zones (area-Spect2 and area-Spect3), beam energy 5 keV, beam size 1 µm². C_{Kα1} = 0.280 keV, F_{Kα1} = 0.532 keV and Si_{Kα1} = 1.739 keV (middle). Related histogram of the size of crystals averaged at 40+15 µm on > 90% of particles (bottom).

After having determined practical vapor deposition conditions for growing well-dispersed self-assembly of diamondoids as microcrystals—vapor phases, but by crystallization from our functionalized diamondoids in solution (dip-coating, dichloromethane, water) were unsuccessful, giving mainly large area covered with isotropic structurally poorly-defined coated material (see optical microscopy and SEM images in SI).
of growing crystals of nanometer size by a similar vapor deposition technique. A particularly pertinent issue was whether shapes and structures previously obtained from functionalized diamondoids vapor self-assembly would be conserved at the nanoscale. The very first step of deposition process could not be controlled by the simple evaporation placed at 2 mm distance. Deposition on a silicon surface that preferentially oriented macroscopic growth of nanocrystals particles). We were glad to observe that the self-assembly of contamination was achieved from 20 mg of diamondoids as microcrystals. Instead we thus used a three-chamber high vacuum physical vapor deposition (PVD, \(10^{-9}\) mbar) apparatus incorporating in-situ XPS analysis (see Fig. SXPS2 in SI, from 3 a typical C1s peak at 284.0 eV appears). The vapor deposition of 3, that had suitable vapor pressure and led to the growth of well-defined crystalline hexagonal rods, was performed using this PVD apparatus. Diamondoid vapours were brought very close to the substrates through a heating tube placed at 2 mm distance. Deposition on a silicon surface that was treated following a RCA protocol to remove carbon contamination was achieved from 20 mg of 3 heated at 100 °C for 3 h under a low pressure of \(1.4 \times 10^{-6}\) mbar. SEM images of the resulting deposits are provided in Fig. 5. As expected, these deposits were resistant to the SEM analysis conditions. Figure 5 (bottom right) provides a representative histogram of the nanocrystals dispersion. Generally, sizes ranging between 20 and 600 nm were obtained under this conditions. Discrete 30–100 nm nanocrystals were obtained in majority (>70% of the particles). We were glad to observe that the self-assembly of 3 mostly exhibit hexagonal shapes with well-defined growth directions. These growth directions were not induced by the Si(111) substrate since an amorphous SiO\(_2\) thin layer is always present at the surface of the substrate before deposition as confirmed by XPS (with O1s peak of SiO\(_2\) found at 532.5 eV, see Fig. SXPS1 in SI). Accordingly, owing to non-preferentially oriented macroscopic growth of nanocrystals some were positioned perpendicularly to the surface.

![Fig. 5. SEM micrograph of nanocrystals of 1-hydroxydiamantane 3 deposited on Si(111)/SiO\(_2\) by PVD under a pressure \(1.4 \times 10^{-6}\) mbar of argon (left). Magnification on a typical hexagonal-shaped nanocrystal (top right) and related histogram of the size of nanocrystals (bottom right).](image)

In the SEM picture Fig. 5 (left) these diamondoid particles can be easily identified and the images allowed measuring their thicknesses, which were remarkably regular around 20 nm. This regularity suggests a fairly homogeneous growth rate of the diamondoid particles. EDX analysis with a beam focusing on the edifices (beam energy 5 keV, size 1 \(\mu\)m\(^2\)) showed that the deposit of 3 exclusively contain carbon and oxygen, in full agreement with the chemical nature of the deposit (see Fig. SEDX1 in SI). We therefore demonstrated that particles of 3 of approximately 20 nm thickness and size can be deposited from a vapor phase under strictly anaerobic and low-pressure conditions (\(1.4 \times 10^{-6}\) mbar), showing self-assembly into hexagonal structures similar to the microstructures formed at micrometer scale under few mbar pressure. This could be straightforwardly extended to the other nanodiamonds 4 and 5.

The relation between the self-assemblies morphology and the functional groups in the molecular precursor is for now difficult to rationalize. This is related to the recognized general non-predictability of molecular structure and morphology of crystals. Accordingly, complexity in polymorphism of functionalized diamondoids has been recently illustrated for adamantane halide derivatives. Nevertheless, it is worth mentioning the excellent reproducibility which is obtained from this approach in the formation of robust well-defined self-assemblies. This attractive method is very simple and in our case outperforms in terms of quality dip-coating popular methods (see SI). Accordingly, this mild temperature vapor phase deposition approach is expected to allow for an easy formation of diamondoid nanoobjects on different types of substrates, including sensitive ones.

**Conclusions**

In summary, we report on readily accessible processes for the mild vapor deposition of functionalized nanodiamonds to provide previously unobserved self-assembly of organic micro- and nanocrystals. Key thermodynamic data including sublimation enthalpy of several diamondoid derivatives are reported from a new measurement protocol at solid-vapor thermodynamic equilibrium state. The conditions of pressure used for the depositions are crucial and if appropriately adjusted lead to deposits resistant to high vacuum and high energy beams. Vapor deposition under atmospheric pressure of air or argon led to unprecedented assemblies that apparently capture gases, and turn to hollow edifices upon gas evacuation. Finally, depending on the type of functional group and its position on the diamondoid, the general structure of the discrete deposits can vary dramatically and anisotropic structures such as rods, needles, triangles or truncated octahedra form. Self-assembled edifices of sizes ranging from 20 nm to several hundred micrometers can be obtained with conservation of a similar geometry for a given diamondoid. Our on-going work aims at using these diamondoid self-assemblies having reactive functions (OH, F) as supports and seeds for metal deposition and organohybrid diamond constructions.

**Experimental**

**General.** Pristine adamantane and diamantane were prepared and purified by sublimation before use. 1-Aminoadamantane
and 1-hydroxyadamantane were obtained from commercial sources. 1-Hydroxydiamantane, 4-hydroxydiamantane, and 4,9-dihydroxodiamantane were synthesized from diamantane;\textsuperscript{10} 4-fluorodiamantane and 4,9-difluorodiamantane were prepared from its hydroxyl derivatives.\textsuperscript{31} Syntheses of other functionalized nanodiamonds were from literature reports. Full details of vapor pressure measurements, vapor deposition of functionalized diamondoids, apparatus, including PVD, and all characterization are described in the Supporting Information.

Mild controlled self-assembly of functionalized nanodiamonds from vapor phases. A functionalized diamondoid (1-5) was placed in a DSC cup on a boron nitride heating element. The substrate was placed above this DSC cup and separated by a ceramic spacer. The whole system was sealed using copper gasket and a valve that was connected to either vacuum ramp (5 mbar pressure), or argon (1 atm), or air (1 atm). With the vacuum ramp the inner gas was removed by pumping for 5 min, and then sublimation was started by adjusting the intensity of the current and duration of deposition. After adjusting the intensity of the applied current the deposition could start. The temperature setting was also monitored as a function of time. After the deposition time, the source was switched off allowing the system to cool. Once the temperature dropped below 30 °C, the system was opened, the source was switched off allowing the system to cool. Once the temperature dropped below 30 °C, the system was opened, the source was switched off allowing the system to cool. After cooling, the sample was removed from PVD apparatus, and to avoid its altering it was stored sealed in a freezer at 4 °C.

Physical vapor deposition. Typically a Si(111) wafer 1x1 cm\textsuperscript{2} was cleaned from carbon-based contamination with RCA clean procedure (see SI) and put inside the heating chamber of PDV apparatus. An amorphous SiO\textsubscript{2} thin layer forms, the Si(111)/SiO\textsubscript{2} then was heated by induction at 800 °C for 12 min, and then moved into the vacuum main deposition chamber indicating an initial pressure of 1.6x10\textsuperscript{-5} mbar. A glass tube containing 1-hydroxydiamantane (3) was purged before connection valve opened and then heated with heating wire at around 80 °C for 3 h, the pressure increasing thus to about 1.4x10\textsuperscript{-6} mbar. In-situ XPS analysis allowed monitoring the deposition process. After cooling, the sample was removed from PVD apparatus, and to avoid its altering it was stored sealed in a freezer at 4 °C.

Acknowledgements

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Notes and references

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\textsuperscript{f} Electronic Supplementary Information (ESI) available: Full details of vapor pressure measurements, vapor deposition of functionalized diamondoids, apparatus (including PVD) and all characterization for all functionalized diamondoids self-assembly from vapor phases and solution dip-coating. See DOI: 10.1039/b0000000x/


7 We reserve “nanodiamond” as a generic name for mixtures of compounds (mostly originating from CVD or detonation methods), and in singular form because it is a class of materials. The term “nanodiamonds” used for diamondoids on the other hand implies, because of plural, that the individual entities can be counted, that is, they have to be uniform and discernible nanometer sized molecules.


Few diamondoid-based hybrid compounds exist, see for cluster and MOOF species:


Concerning diamantane, enthalpy of sublimation \( \Delta H^0 = 117.2 \pm 8 \text{ kJ mol}^{-1} \) was reported (see ref. [18]) that was calculated from the sum of the enthalpy of vaporization and the enthalpy of fusion, see: A. S. Carson, P. G. Laye, W. V. Steele, D. E. Johnston, M. A. McKervey, J. Chem. Thermodyn. 1971, 3, 915. Various other methods have been used which conversely gave for diamantane \( \Delta H^0 \) values ranging between 73 and 97 kJ/mol (see also SI).

The identical sublimation enthalpy values reported at 116-118 kJ mol\(^{-1}\) for diamantan-1-ol, diamantan-3-ol and diamantan-4-ol are questionable and may be overestimated according our measurements (see ref. [21]). Accordingly, DSC measurements of the melting points for 3 and 4 also showed \( \Delta H \) discrepancies with values substantially different for 1-hydroxydiamantane and 4-hydroxydiamantane: 137 \( \pm 1 \)°C and 177\( \pm 1 \)°C, respectively. DSC measurements on cooling were also achieved for determining crystallization peaks that gave single peaks excluding polymorphism of 3 and 4 between 25 and 210 °C.

